				Time stamp
Number	Hits	Search Text	DB USPAT	2002/04/03 10:14
Number		(420/502) CCIS	USPAT	2002/04/03 10:17
	125	(1/420/502) CCT.S.) and ((tin (ti titanium)	USFAI	2002, 01, 00
•		ad: mitride) same (w tungsten co cobarc))	USPAT	2002/04/02 13:01
	9420	((Metaly) to the control same	USTAL	
		tantalum titanium tungsten W aluminum al)		
		near3 (nitride\$1 oxy\$1nitride\$1)) tin aln		1
		tan tion)	USPAT	2002/04/02 13:03
	1720	((diffusion barrier) same (((metal\$3 ta ti	OSIAI	
		tantalum titanium tungsten W aluminum al)		
		l /nitride\$1 oxy\$ nitride\$1// Lill dill		
		tan tion)) and (fsg bpsg psg bsg sillcate	}	
		lada aloce\$2 siOf)	USPAT	2002/04/02 13:14
-	1790	(((diffusion barrier) same (((metal\$3 ta	001711	
		ti tantalum titanium tungsten W aluminum		
	İ	lall noar3 (nitrideS1 oxy\$Initride\$1/) till		
		lalm tan tion)) and (doped adl (Oxideal		
		diovide(1)) (((diffusion barrier) same		
		1//matale3 ta ti tantalum titanium		
		tungsten W aluminum al) near3 (nitride\$1		
		oxy\$1nitride\$1)) tin aln tan tion)) and		
		(fsg bpsg psg bsg silicate adj glass\$2		
		-:-e\\	USPAT	2002/04/02 13:20
_	1770	(((diffusion barrier) same ((metal\$3 ta	OSIAI	
		le: tantalum titanium tungsten w arumirum		
		1 -11 many (nitrides) OXVSINITTIGE 71// CIII	1	
	ļ	all hears (hittrady on the same all hears (hittrady on the same all hears (hittrady on the same all hears of the same all hears on the same all hears on the same all hears of the same all hears on the same all hears of t		
		diovide(1))) (((diffusion parrier) same		
		(((metal\$3 ta ti tantalum titanium		
		tungsten W aluminum al) near3 (nitride\$1		
		oxy\$1nitride\$1)) tin aln tan tion)) and		
		lifed has a use high sillicate ad glassyz		Ì
	•	siof))) and (temperature\$1 thick\$4	ļ	
	1	pressure\$1 plasma power rf frequenc\$3)	USPAT	2002/04/02 13:3
_	1237	1 /420/627 628 643 644.653.6341.0043.		2002/04/02 17:2
_	262	(((((diffusion barrier) same (((metal\$3 ta	052111	
		ti tantalum titanium tungsten W aluminum		
		-1\ nong2 (nitrideS) OXV\$INITTIGE?1)/ C111		
		lain ton tion)) and (doped ad) (OXIGEY)		
		dioxide\$1))) (((diffusion barrier) same		
		(((metal\$3 ta ti tantalum titanium		
		tungsten W aluminum al) near3 (nitride\$1	į	
		oxy\$1nitride\$1)) tin aln tan tion)) and	İ	
	Ì	/fag bosg had sillicate adj glassyz		
		1 - ELL and /tomporatureSI EDICK94		
		1		Ì
	,	$\frac{1}{2}$	USPAT	2002/04/02 17:3
_	793	a ///matale3 ta ti tantalum tildiiium	1 002	
	1	tungeton W aluminum all nears (nittides)		
	Ì	oxy\$1nitride\$1) tin aln tan tion) and		
	l	(doned near3 (oxide\$1 dloxide\$1 glass\$27		
		ly hea hosa fsa siof DSQ)	USPAT	2002/04/02 17:3
_	ļ	0 (((metal\$3 ta ti tantalum titanium		
1		tungsten W aluminum al) near3 (nitride\$1		
		oxy\$1nitride\$1)) tin aln tan tion) and		
1	1	((doped near3 (oxide\$1 dioxide\$1 glass\$2)		
	1) bsg bpsg fsg siof psg)) and (1	
]	(((metal\$3 ta ti tantalum titanium		
	ļ	tungator Waluminum all nears (nitrides)	•	\
		l 61 mit mide \$1\\ tin aln tan tlon/ Same	1	
		//- nitrogen) near2 rich near2 pidsma//	USPAT	2002/04/02 17:
_	10	sal / ///matales ta ti tantalum titanium	1	
1		Langeton Waliminim all nears (nitrides)		
		l Anniewidaelll tin aln tan Elon) dhu		
		//dopod near3 (oxideSl dlox1de31 gldSS42)	'	1
) has been fee siof DSQ) and (İ
		l ///tales to ti tantalim Elldiilui	,	
	l	lauraton Waliminim all nears (nicitude)	-	1
1	1	lovy\$1nitride\$1)) tin ain tan tion, same		
ı	1	((n nitrogen) near10 plasma))		

_	104		USPAT	2002/04/02 17:50
	1	tungsten W aluminum al) near3 (nitride\$1		
	1	oxy\$1nitride\$1)) tin aln tan tion) and		
		((doped near3 (oxide\$1 dioxide\$1 glass\$2)		
) bsg bpsg fsg siof psg)) and (
		(((metal\$3 ta ti tantalum titanium	1	
		tungsten W aluminum al) near3 (nitride\$1		
1		oxy\$1nitride\$1)) tin aln tan tion) same		
		((n nitrogen) near10 plasma))) and (
		(((metal\$3 ta ti tantalum titanium		1
		tungsten W aluminum al) near3 (nitride\$1		
		oxy\$1nitride\$1)) tin aln tan tion) same		-
		((n nitrogen) near10 plasma))		2002/04/02 17:52
-	81		USPAT	2002/04/02 17:52
ł		tungsten W aluminum al) near3 (nitride\$1		
		oxy\$1nitride\$1)) tin aln tan tion) and		
		((doped near3 (oxide\$1 dioxide\$1 glass\$2)		
) bsg bpsg fsg siof psg)) and (
	1	(((metal\$3 ta ti tantalum titanium		
		tungsten W aluminum al) near3 (nitride\$1		
		oxy\$1nitride\$1)) tin aln tan tion) same		
	- [((n nitrogen) near10 plasma))) and (
		(((metal\$3 ta ti tantalum titanium		
		tungsten W aluminum al) near3 (nitride\$1		
		oxy\$1nitride\$1)) tin aln tan tion) same ((n nitrogen) near10 plasma))) and (
		(temperature pressure thick thickness rf		
		frequenc\$3 power watt\$1) same ((n		
	1	nitrogen) near10 plasma))		
1	1	INTEROGENTY MEGETTA PERSONALLY		